Amendments to the Claims:

The following Listing of Claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims

- 1. (Presently Amended) A laminated flip-chip interconnect package comprising a substrate having a chip attach surface and a <u>an opposing</u> board attach surface that define contact pads for attachment to corresponding pads on the chip and board, wherein the <u>substrate</u> board attach surface comprises <u>contact pads opposite a chip attach location and regions adjacent the chip attach location on the chip attach surface except at least one solid plane <u>covering the area of the board attach surface</u>, <u>said area being opposite a chip attach surface region near adjacent a at least one chip corner of a chip attach location</u>, <u>and said solid plane board attach surface</u> comprising a dielectric material.</u>
- 2. (Presently Amended) A laminated flip-chip interconnect package according to claim 1 wherein said dielectric material is covered with a layer of material selected from a soldermask solder mask and a coverlay material.
- 3. (Original) A laminated flip-chip interconnect package according to claim 2 wherein said layer of material is selected from the group consisting of polyimide, polytetrafluoroethylene, and expanded polytetrafluorethylene impregnated with cyanate ester and epoxy.
- 4. (Presently Amended) A laminated flip-chip interconnect package comprising a substrate having a chip attach surface and a <u>an opposing</u> board attach surface that define contact pads for attachment to corresponding pads on the chip and board, wherein the <u>substrate</u> board <u>attach</u> surface comprises at least one solid plane-covering the <u>area</u>, said area being opposite a chip attach surface region <u>near</u> adjacent at least one the chip corner[[s]] of a chip attach location, and said <u>board attach surface solid plane</u> comprising a metal.
- 5. (Original) A laminated flip-chip interconnect package according to claim 4 wherein said metal is selected from the group consisting of copper, silver, gold and aluminum.

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6. (Presently Amended) A laminated flip-chip interconnect package according to claim 4 wherein said metal is covered with a layer of material selected from a soldermask solder mask and a coverlay material.

- 7. (Original) A laminated flip-chip interconnect package according to claim 6 wherein said layer of material is selected from the group consisting of polyimide, polytetrafluoroethylene, and expanded polytetrafluorethylene impregnated with cyanate ester and epoxy.
- 8. (Presently Amended) A laminate flip-chip interconnect package according to claim 4 wherein said soldermask solder mask has a plurality of openings defining ball grid array pads.

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